

Form PTO 1449 (Modified)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY DOCKET NO. 292134US26PCT ✓		SERIAL NO. 10/581,601 ✓	
LIST OF REFERENCES CITED BY APPLICANT				APPLICANT Masaru SASAKI, et al.			
				FILING DATE June 5, 2006		GROUP 2812	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE	
/S.J.N./	AA	6,319,842 B1	11/20/2001	Mukul KHOSLA, et al.			
/S.J.N./	AB	6,107,192	8/22/2000	Suchitra SUBRAHMANYAN, et al.			
/S.J.N./	AC	2004/0134613 A1	7/15/2004	Tadahiro OHMI, et al.			
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	AN						
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	TRANSLATION YES NO		
/S.J.N./	AO	EP 1 081 750 A2	3/7/2001	Europe (corresponds to previously filed JP 2001-203194)			
/S.J.N./	AP	WO 01/29879 A2	4/26/2001	WIPO			
/S.J.N./	AQ	JP 2001-85331	3/30/2001	Japan (with English Abstract and English translation)	X		
/S.J.N./	AR	EP 1 300 878 A1	4/9/2003	Europe (corresponds to US 2004/0134613 A1)			
	AS						
	AT						
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OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.)							
/S.J.N./	AW	Gi-Chung KWON, et al., "New Plasma Source Development Using a Parallel Resonance Antenna for Dry Etching", IEEE International Conference on Plasma Science, vol. CONF. 30, June 2, 2003, XP010658995, page 403					
	AX						
	AY						
	AZ					<input type="checkbox"/> Additional References sheet(s) attached	
Examiner /Seahvosh Nikmanesh/				Date Considered 06/03/2009			
*Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							